

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(method and seal\$3 and nitride and oxide and contact and open\$3 and expos\$3 and sidewalls and ((reactive adj ion adj etching) or rie) and mask).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 10:35

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L1	1	(method and seal\$3 and nitride and oxide and contact and open\$3 and expos\$3 and sidewalls and ((reactive adj ion adj etch\$3) or rie)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 11:25